

Physics 53600  
**Electronics Techniques for  
Research**

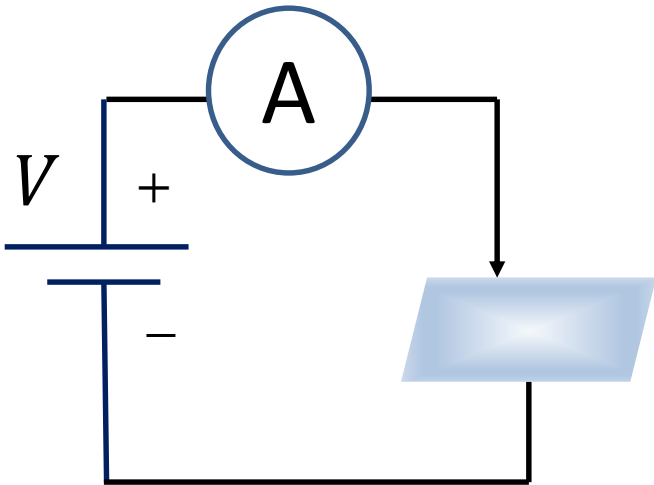
***Now in PowerPoint!***

Spring 2020 Semester

Prof. Matthew Jones

# Semiconductors

- Prior to 1874, it was thought that all materials satisfied Ohm's law
- Ferdinand Braun discovered some minerals violated Ohm's law (eg. lead sulfide)

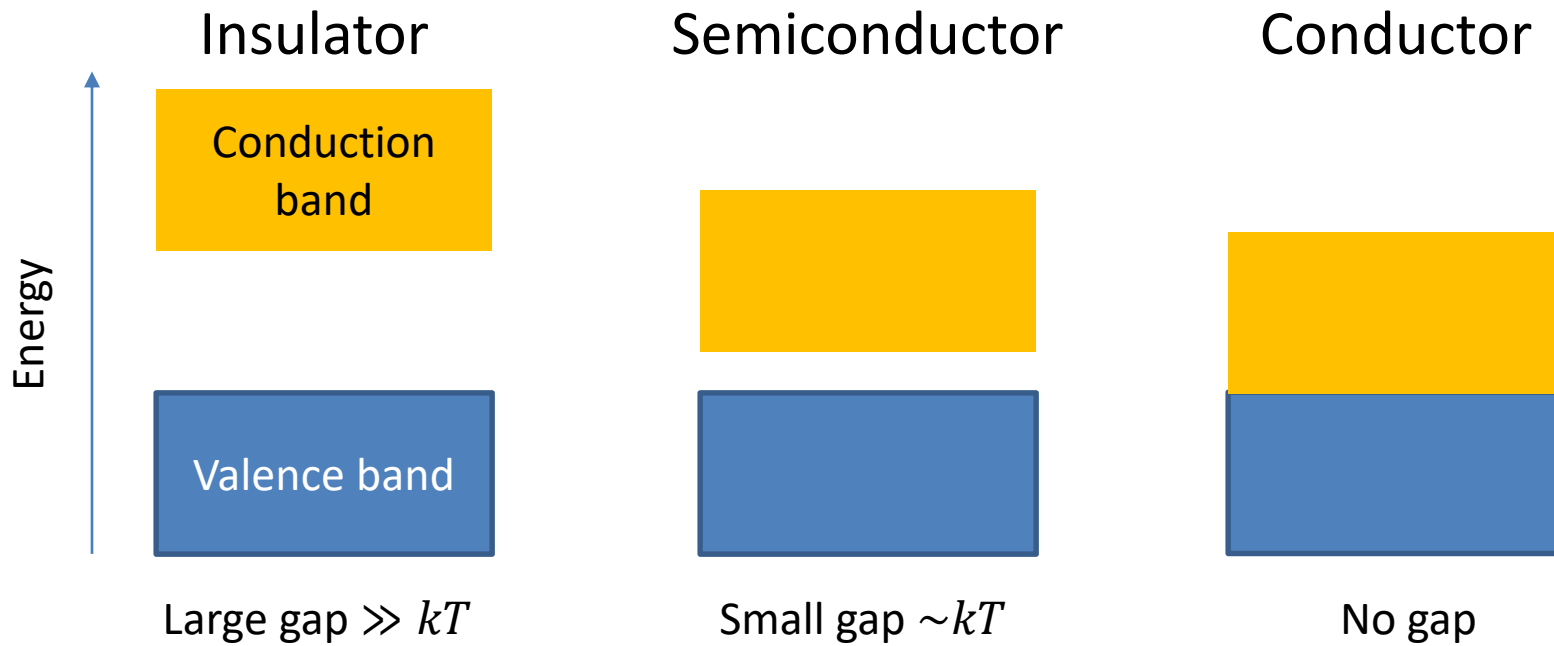


# Semiconductors

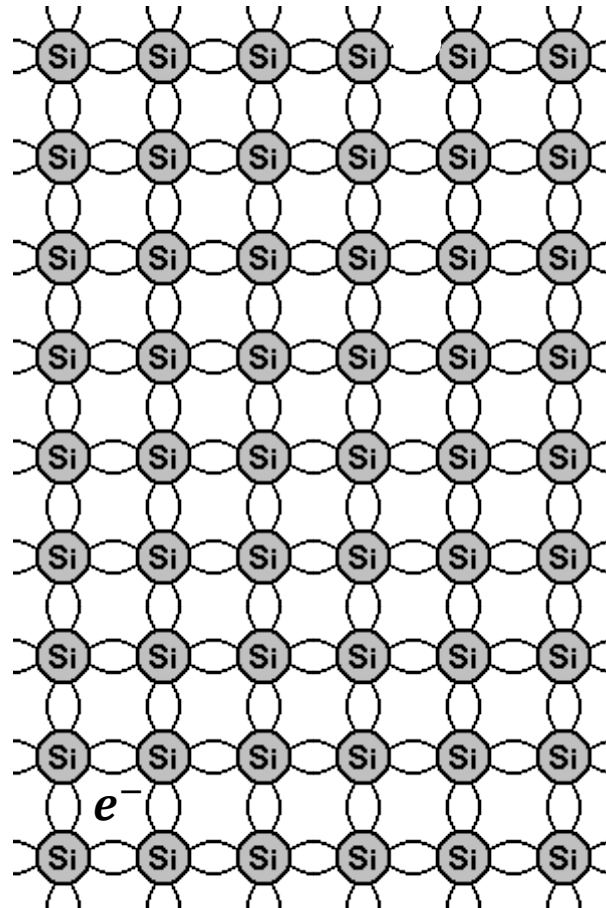
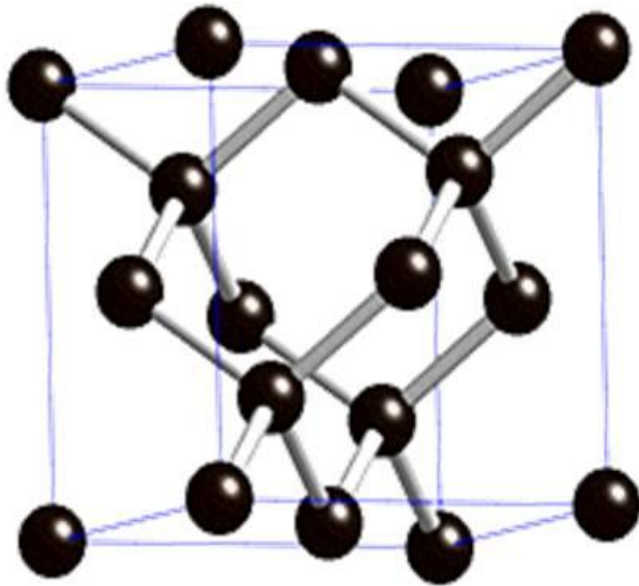
- Observations:
  - Resistance depended on polarity of the voltage source (30% effect)
  - Resistance decreased as current increased
- Hall effect (1879):
  - Magnetic fields deflect charge carriers
  - Most materials had negative charge carriers
  - Some had positive charge carriers

# Electron Energy Bands

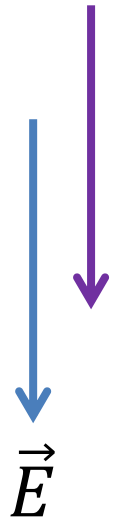
- A.H. Wilson (1931): electrons exist with discrete energy levels



# Intrinsic Semiconductors



$$\vec{J} = qn\vec{v}$$



# Intrinsic Semiconductors

- Current density:

$$\begin{aligned} J &= \sigma E \\ &= e(n_i \mu_n + p_i \mu_p) E \end{aligned}$$

- Charge carrier densities:
  - $n_i$  is the density of electrons (negative)
  - $p_i$  is the density of holes (positive)
- Intrinsic semiconductors:

$$n_i = p_i$$

- Charge carrier mobility:

$$\mu_n > \mu_p$$

# Example

- Silicon at room temperature:

$$N_{Si} = 5 \times 10^{28} \text{ atoms/m}^3$$

$$p_i = n_i = 1.5 \times 10^{16} \text{ /m}^3$$

$$\mu_n = 0.135 \text{ m}^2/\text{V} \cdot \text{s}$$

$$\mu_p = 0.048 \text{ m}^2/\text{V} \cdot \text{s}$$

- Conductivity:

$$\sigma = 4.4 \times 10^{-4} \Omega^{-1}\text{m}^{-1}$$

- Resistivity: consider 1 mm x 1 mm x 1 cm...

$$R = \frac{L}{\sigma A} = 23 \text{ M}\Omega$$

# Doped Semiconductors

- Suppose we added one extra charge carrier per million Si atoms (donors).

$$N_d \sim 10^{22} \gg n_i$$

- Now it is a good conductor:

$$\sigma \sim e N_d \mu_n \Rightarrow R = 46 \, \Omega$$

- Suppose we added extra holes that sucked up free electrons (acceptors).

$$\sigma \sim e N_a \mu_p \Rightarrow R = 130 \, \Omega$$

- Electrical properties are dramatically changed by small concentrations of dopant atoms

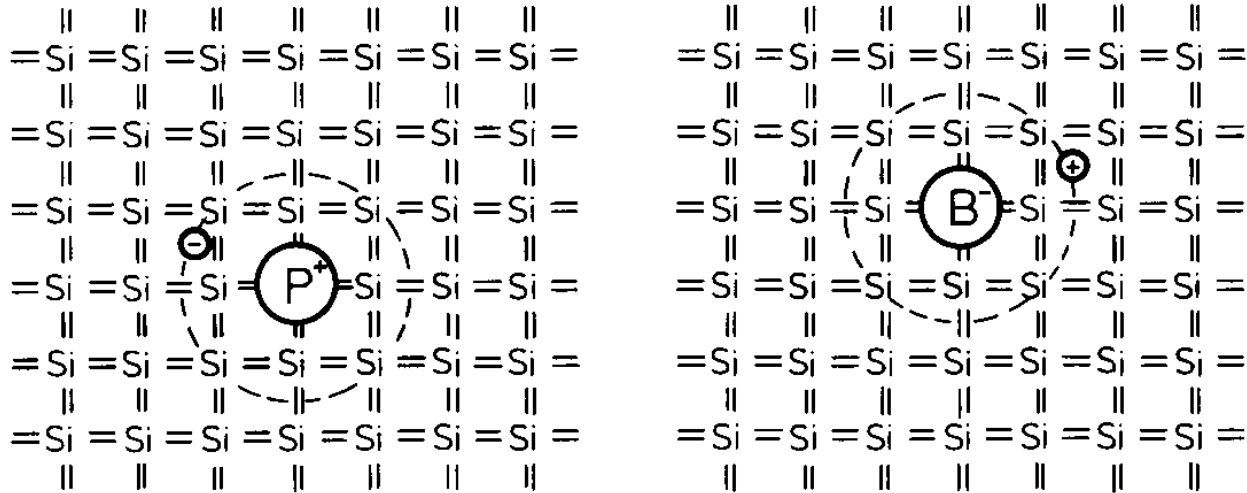


# Doped Semiconductors

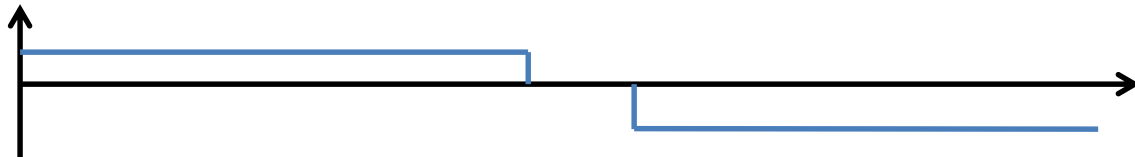
- Donor impurities:
  - Phosphorus
  - Arsenic
  - Antimony
 } n-type
- Acceptor impurities:
  - Boron
  - Gallium
  - Indium
 } p-type

						8A
						2 4.003 <b>He</b> Helium
3A	4A	5A	6A	7A		
5 10.811 <b>B</b> Boron	6 12.011 <b>C</b> Carbon	7 14.007 <b>N</b> Nitrogen	8 15.999 <b>O</b> Oxygen	9 18.988 <b>F</b> Fluorine	10 20.180 <b>Ne</b> Neon	
13 26.982 <b>Al</b> Aluminum	14 28.086 <b>Si</b> Silicon	15 30.974 <b>P</b> Phosphorus	16 32.066 <b>S</b> Sulfur	17 35.453 <b>Cl</b> Chlorine	18 39.948 <b>Ar</b> Argon	
31 69.723 <b>Ga</b> Gallium	32 72.61 <b>Ge</b> Germanium	33 74.922 <b>As</b> Arsenic	34 78.972 <b>Se</b> Selenium	35 79.904 <b>Br</b> Bromine	36 84.80 <b>Kr</b> Krypton	
49 114.818 <b>In</b> Indium	50 118.71 <b>Sn</b> Tin	51 121.760 <b>Sb</b> Antimony	52 127.6 <b>Te</b> Tellurium	53 126.904 <b>I</b> Iodine	54 131.29 <b>Xe</b> Xenon	
81 204.383 <b>Tl</b> Thallium	82 207.2 <b>Pb</b> Lead	83 208.980 <b>Bi</b> Bismuth	84 208.982 <b>Po</b> Polonium	85 209.987 <b>At</b> Astatine	86 222.018 <b>Rn</b> Radon	
113 unknown <b>Uut</b> Ununtrium	114 (289) <b>Fl</b> Flerovium	115 unknown <b>Uup</b> Ununpentium	116 (298) <b>Lv</b> Livermorium	117 unknown <b>Uus</b> Ununseptium	118 unknown <b>Uuo</b> Ununoctium	
66 162.50 <b>Dy</b> Dysprosium	67 164.930 <b>Ho</b> Holmium	68 167.26 <b>Er</b> Erbium	69 168.934 <b>Tm</b> Thulium	70 173.04 <b>Yb</b> Ytterbium	71 174.967 <b>Lu</b> Lutetium	
98 251.080 <b>Cf</b> Californium	99 (254) <b>Es</b> Einsteinium	100 257.095 <b>Fm</b> Fermium	101 258.1 <b>Md</b> Mendelevium	102 259.101 <b>No</b> Nobelium	103 (262) <b>Lr</b> Lawrencium	

# P-N Junction



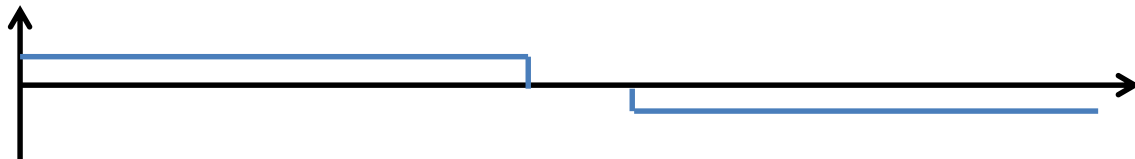
n-type dopant  
concentration



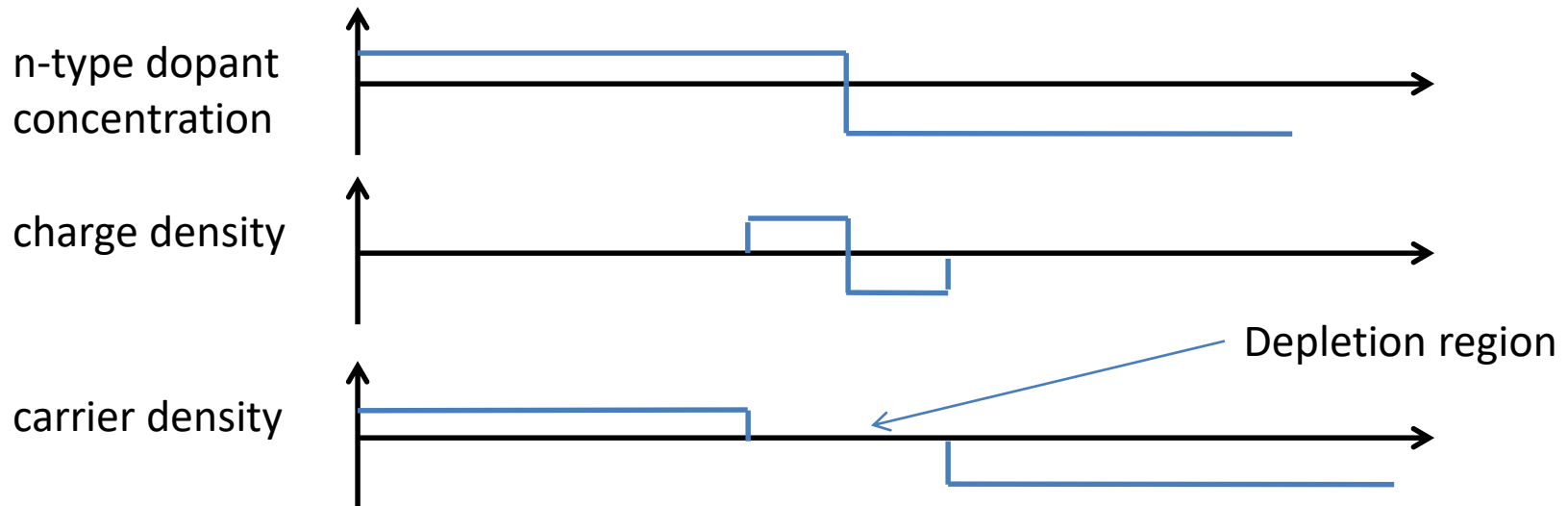
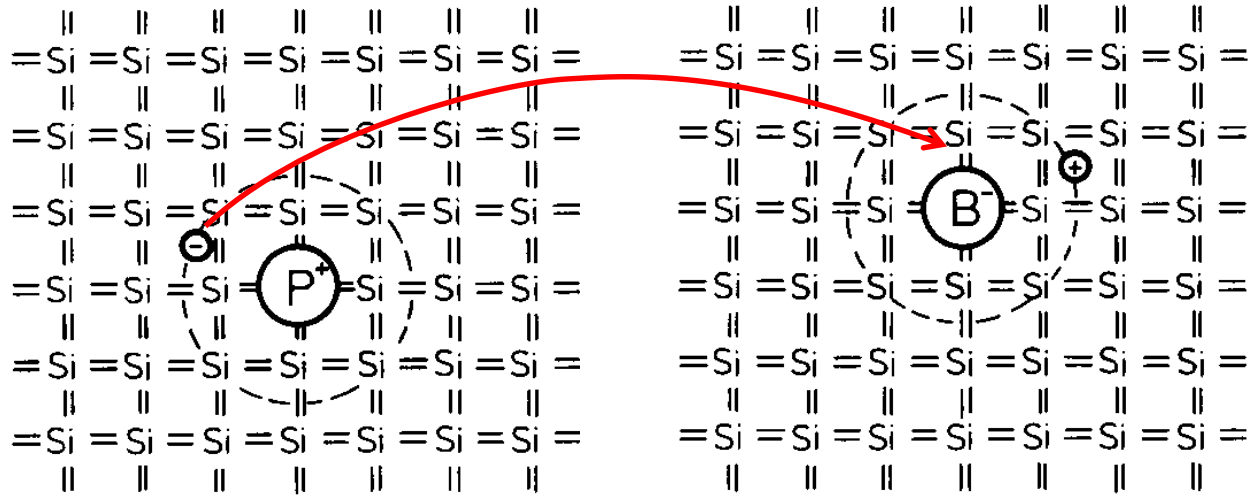
charge density



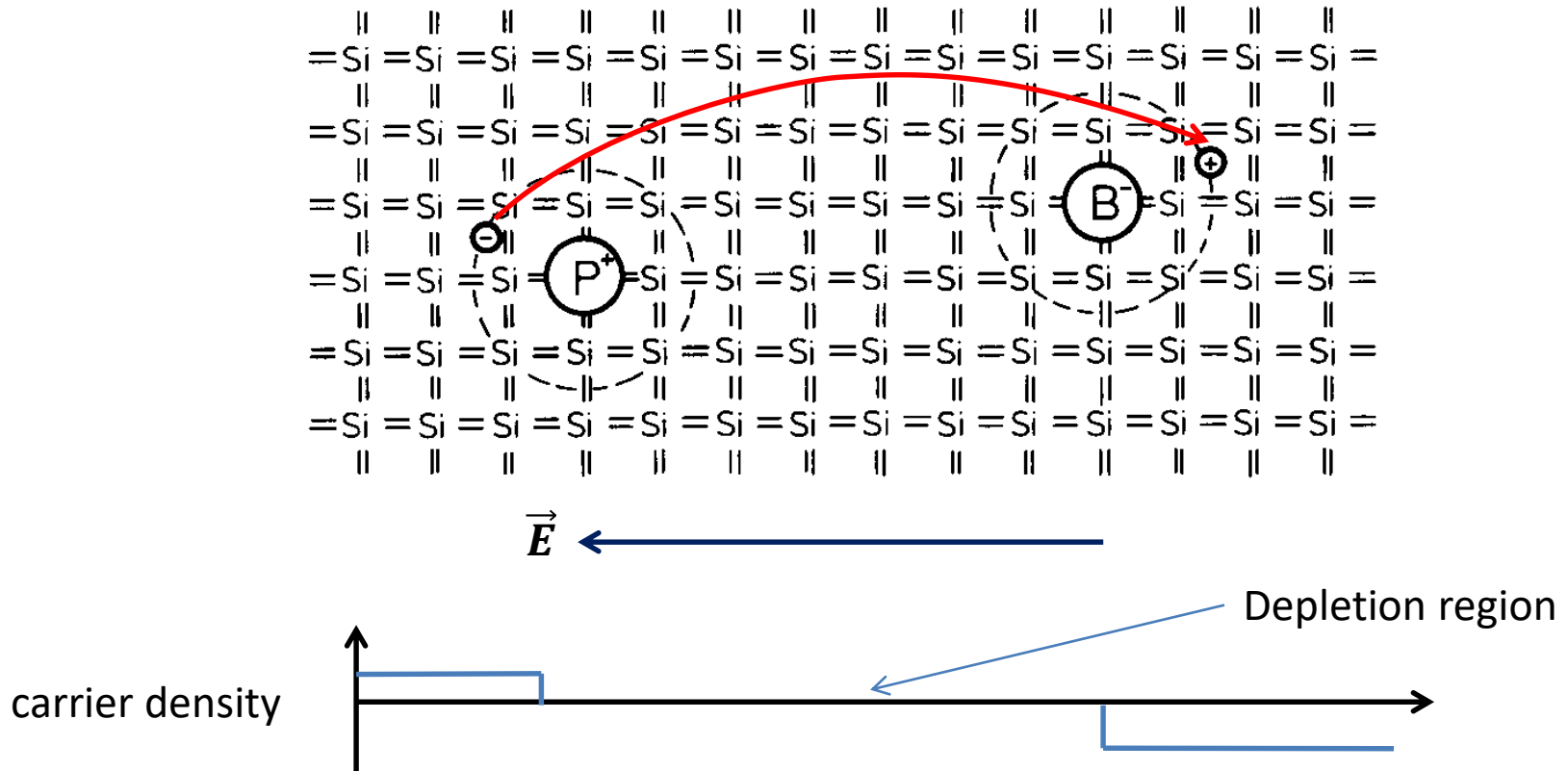
carrier density



# P-N Junction



# P-N Junction



Charge carriers in depletion region created by:

- Thermal excitation
- Ionizing radiation

# P-N Junction

- An electron in the n-side needs a finite amount of energy to jump the gap

$$E_0 = e V_0$$

- Reverse saturation current:

$$I_0 = K e^{-eV_0/kT}$$

- Apply a voltage and introduce charge carriers that diffuse across the junction:

$$I_d = K e^{-e(V_0-V)/kT}$$

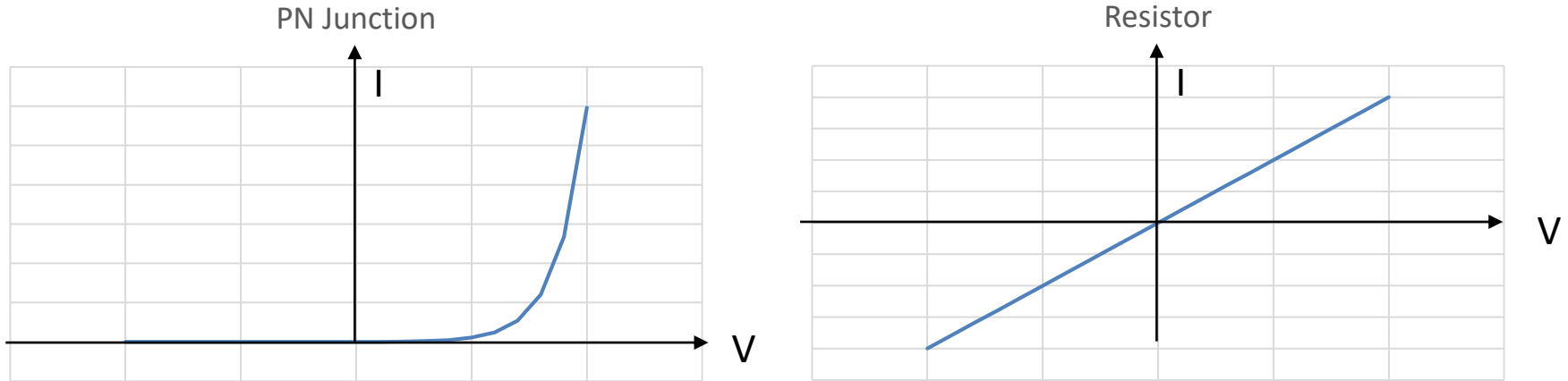
- Total current flow:

$$I = I_d - I_0 = I_0(e^{eV/kT} - 1)$$

- At room temperature,  $kT/e \sim 25$  mV

Shockley equation

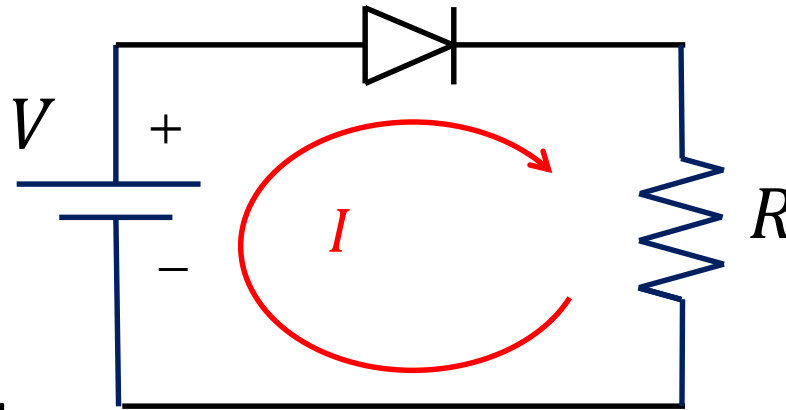
# P-N Junction



- The PN junction diode conducts significant current in only one direction
- Leakage current in an ideal diode is  $\sim 10^{-12}$  A

# P-N Junction

- How does a diode behave in a circuit?



- Kirchhoff's rule:

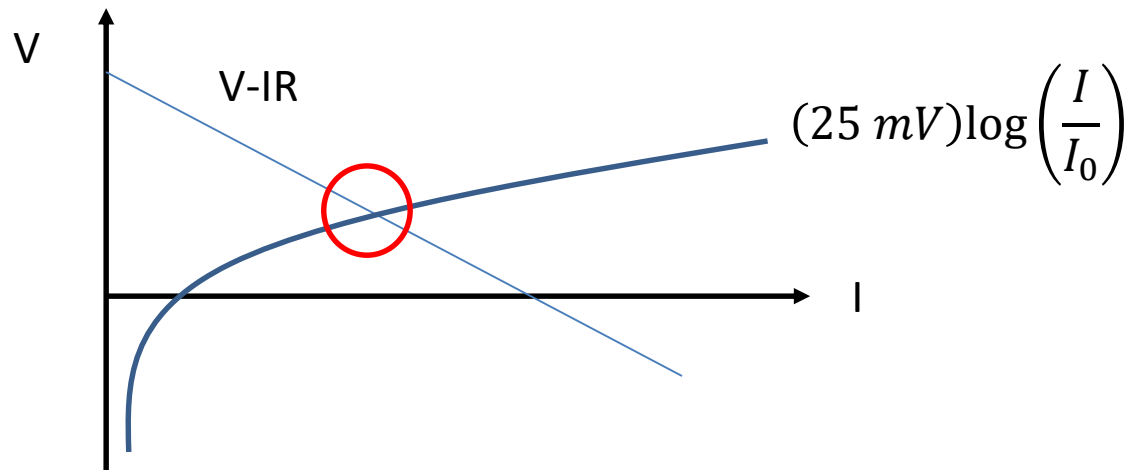
$$V - V_D - IR = 0$$

$$V_D = (25 \text{ mV}) \log \left( \frac{I}{I_0} \right)$$

$$V - IR = (25 \text{ mV}) \log \left( \frac{I}{I_0} \right)$$

# P-N Junction

- This is a transcendental equation
  - It can be solved numerically
  - It can be solved graphically

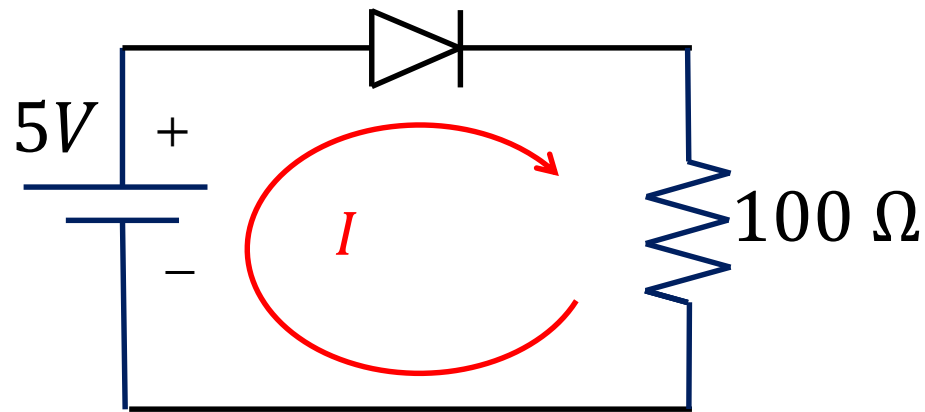


- A solution must exist



# P-N Junction

- Suppose that  $I_0 = 10^{-12}$  A and that  $V_D = 0.727$  V.



- The current in the circuit is

$$I = \frac{5 \text{ V} - 0.727 \text{ V}}{100 \Omega} = 43 \text{ mA}$$

# P-N Junction

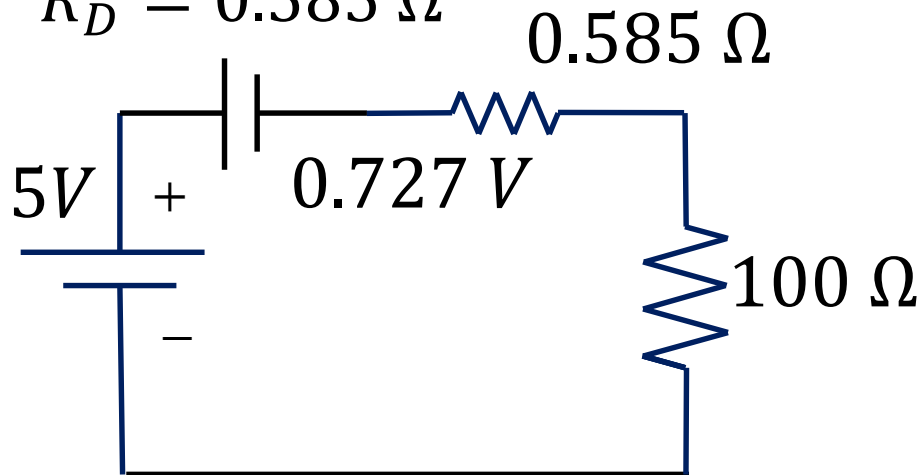
- The “resistance” of the diode is  $R_D = dV_D/dI$

$$R_D = \left( \frac{dI}{dV_D} \right)^{-1} = \left( \frac{I_0 e}{kT} e^{eV_D/kT} \right)^{-1}$$

- In this case,

$$R_D = 0.585 \, \Omega$$

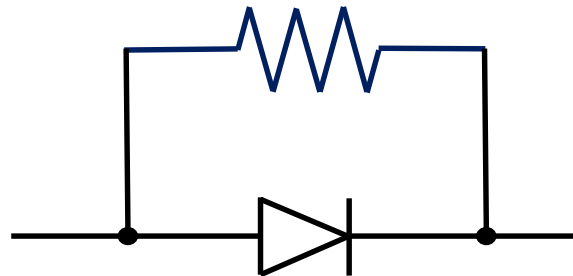
- Equivalent circuit:



- Except for the change in potential across the junction, the diode has a very low resistance.

# Non-Ideal Diode Characteristics

- In practice, the reverse saturation current is not quite constant
- A small amount of current that flows past the junction satisfies Ohm's law (large R)



$$R = \frac{1}{G_{min}}$$

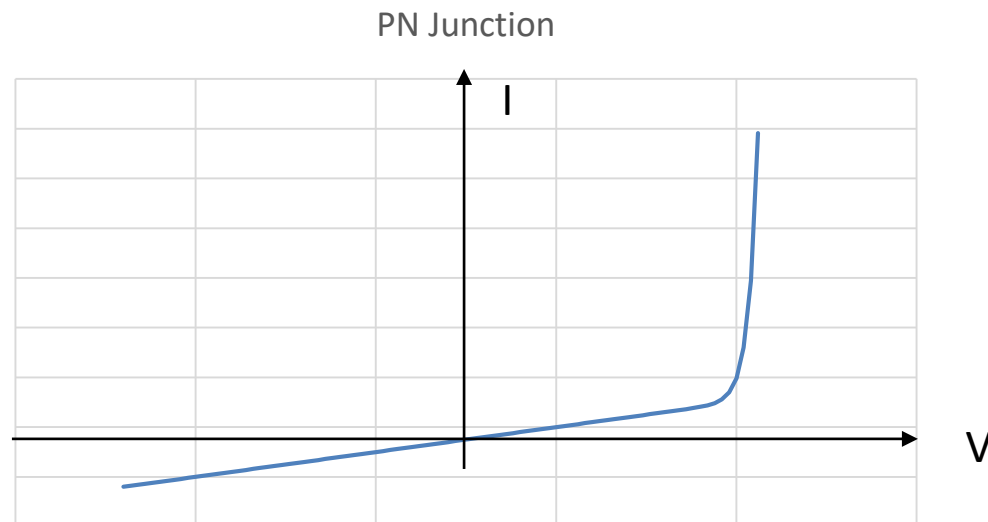
- This is usually specified as a small conductance parameter in diode models
- It also helps with convergence of numerical methods

# Non-Ideal Diode Characteristics

- The Shockley equation gets modified slightly...

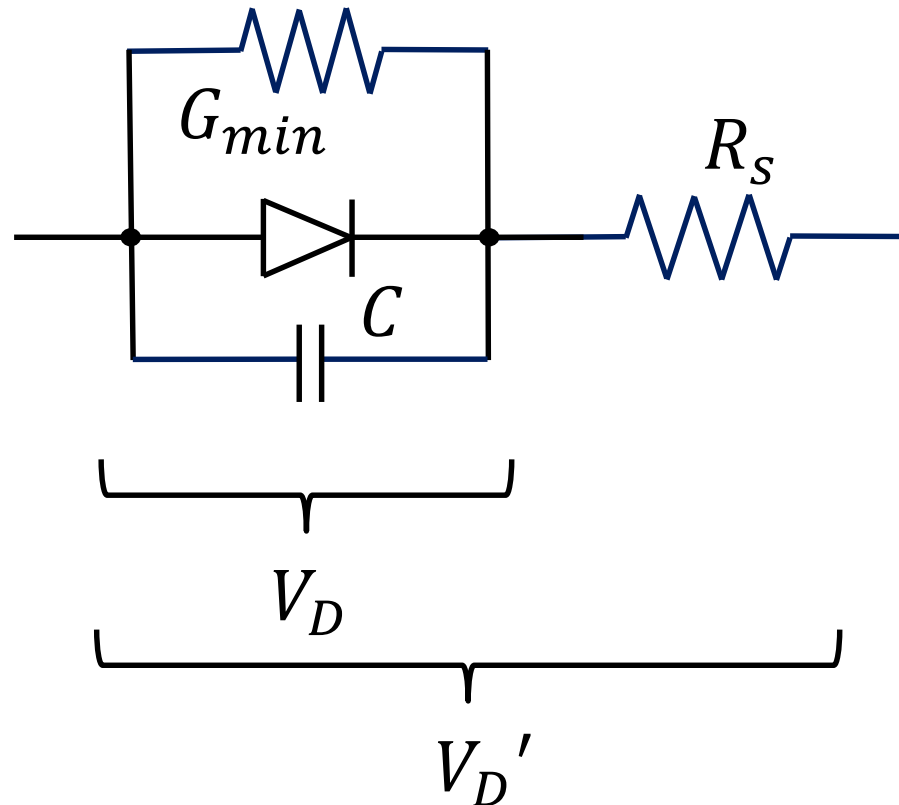
$$I_D = I_0 \left( e^{eV/kT} - 1 \right) + V_D G_{min}$$

- In the forward biased region this has no effect
- In the reverse biased region there is now a tiny slope:



# Non-Ideal Diode Characteristics

- There can also be a small series resistance and capacitance at the junction



# Junction Capacitance

- The width of the depletion region increases with reverse bias voltage
- For a parallel plate capacitor,

$$C = \frac{\epsilon_0 A}{d}$$

- The width of the depletion region does not grow linearly with voltage though...

$$C = \frac{C_0}{\sqrt{1 - \frac{V_D}{V_j}}}$$

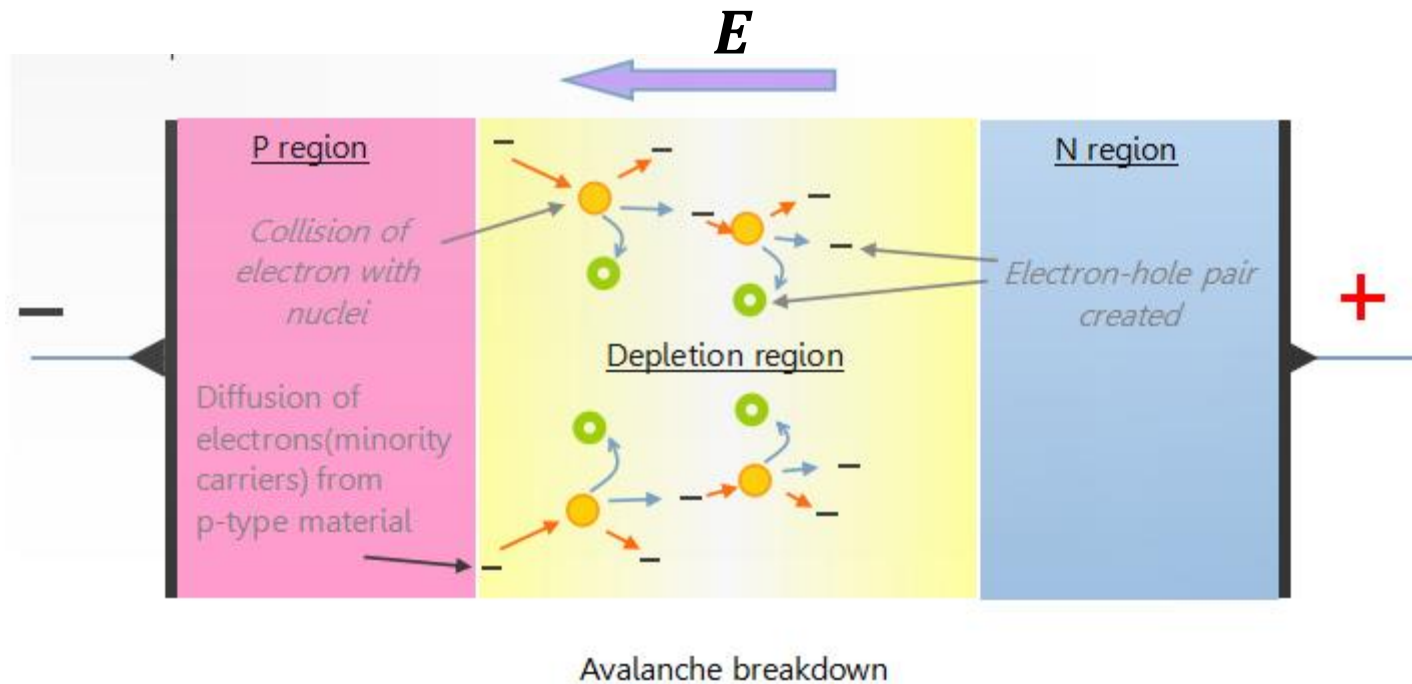
$V_D < 0$  in the reverse biased region.

$V_j$  is the junction potential

# Junction Breakdown

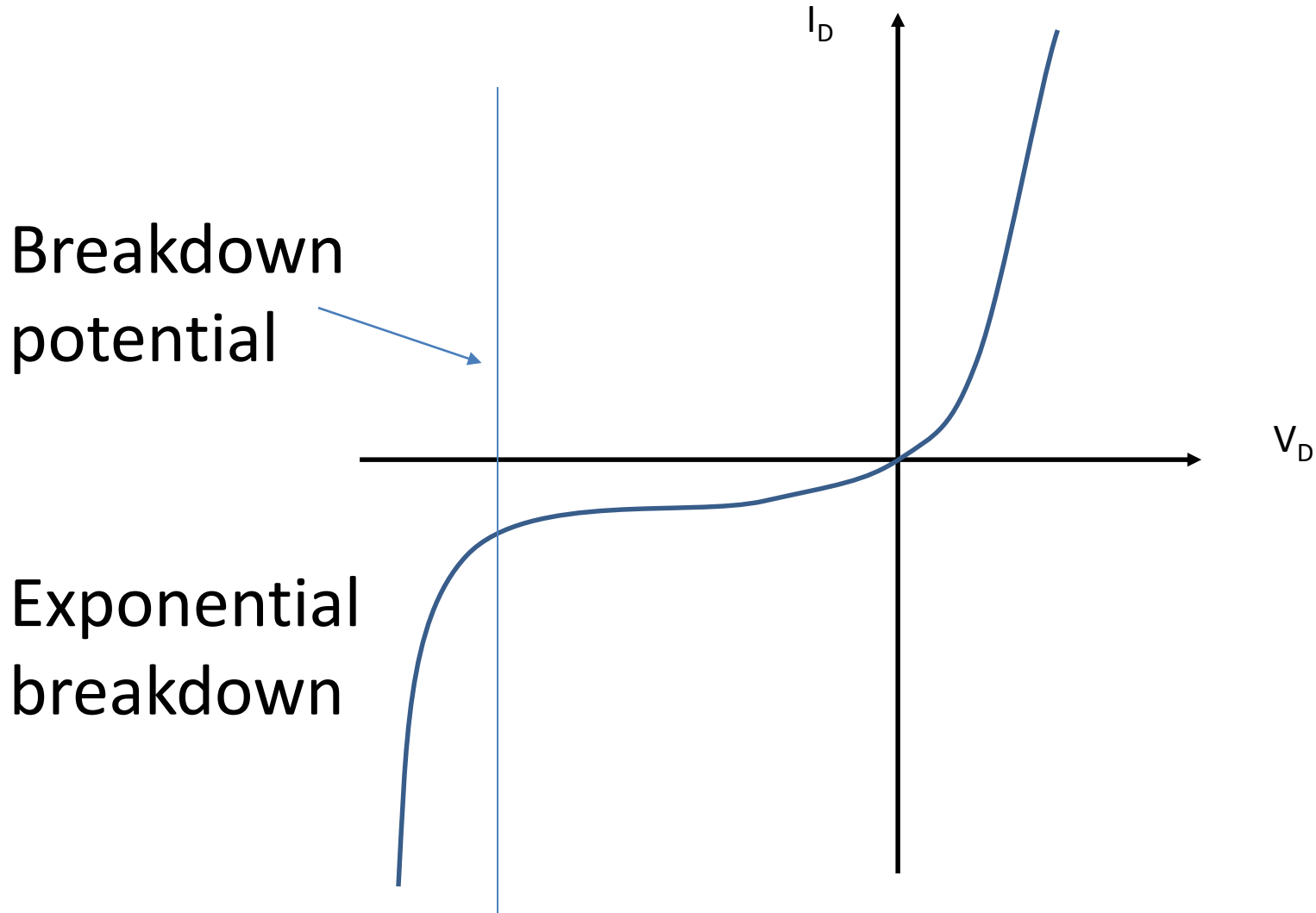
- When the junction is reverse biased with a large potential difference, large electric fields can be present across the junction
- Any charge carriers liberated by thermal excitations will be accelerated
- If they gain enough energy that they can break additional bonds, then an avalanche breakdown occurs

# Avalanche Breakdown



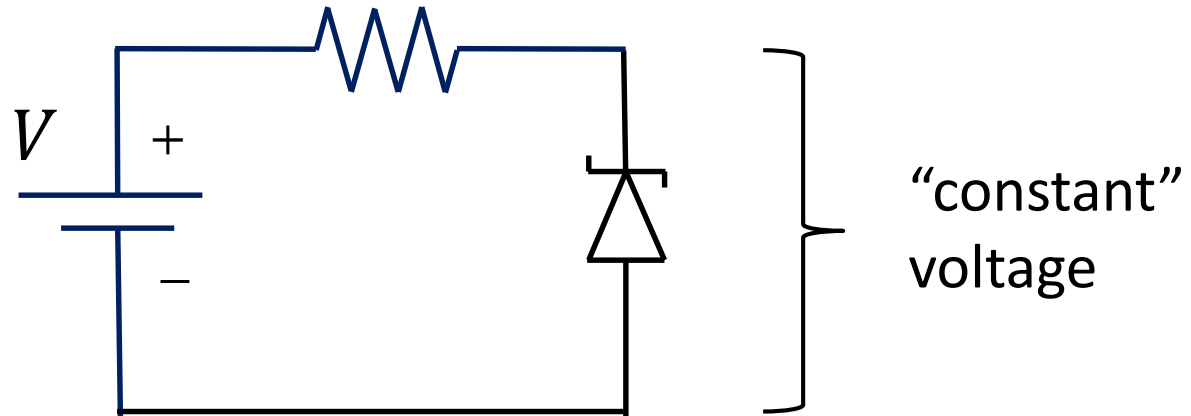


# Avalanche Breakdown



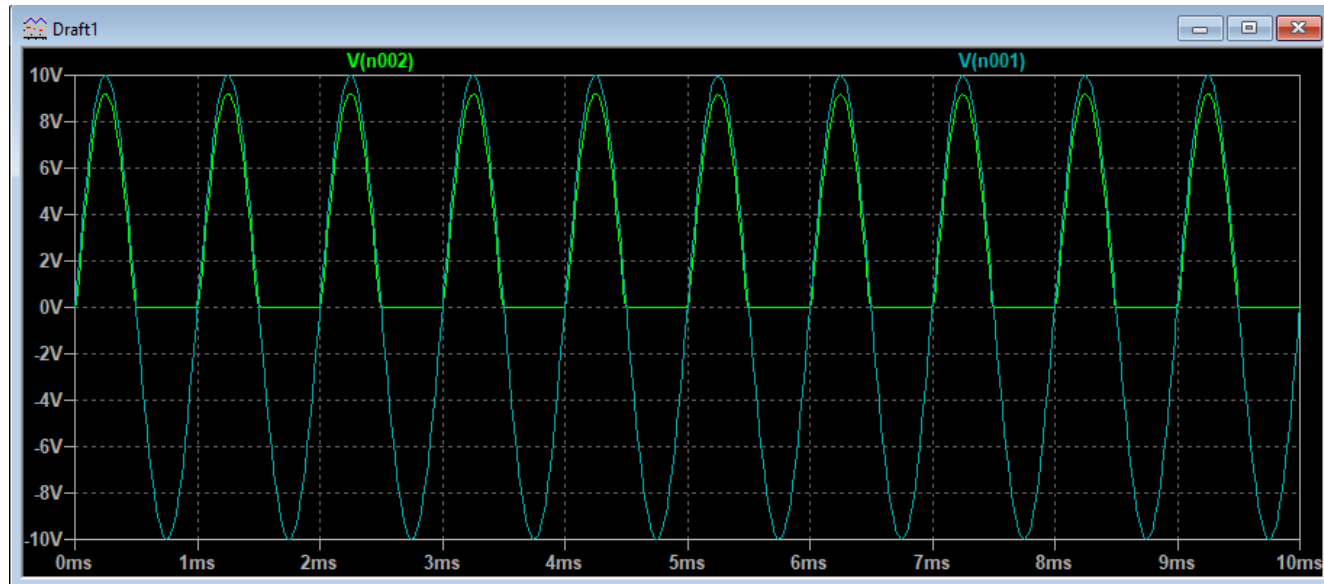
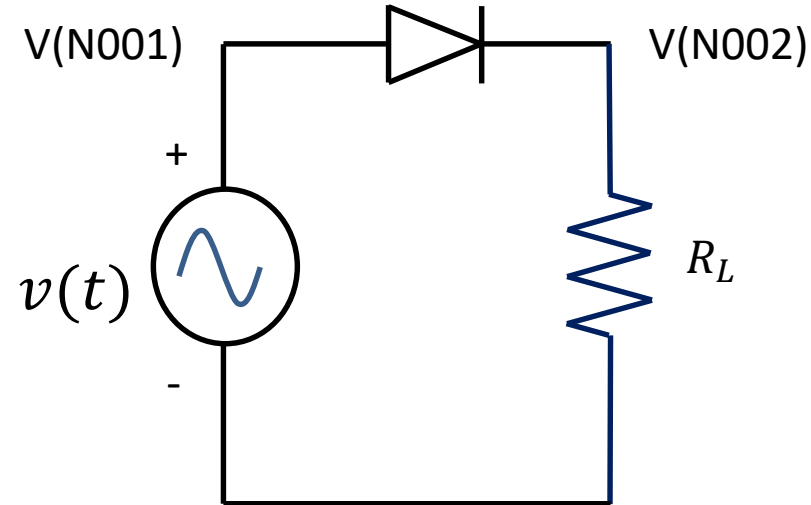
# Zener Diodes

- Zener diodes are designed to break down at a well-controlled reverse bias voltage

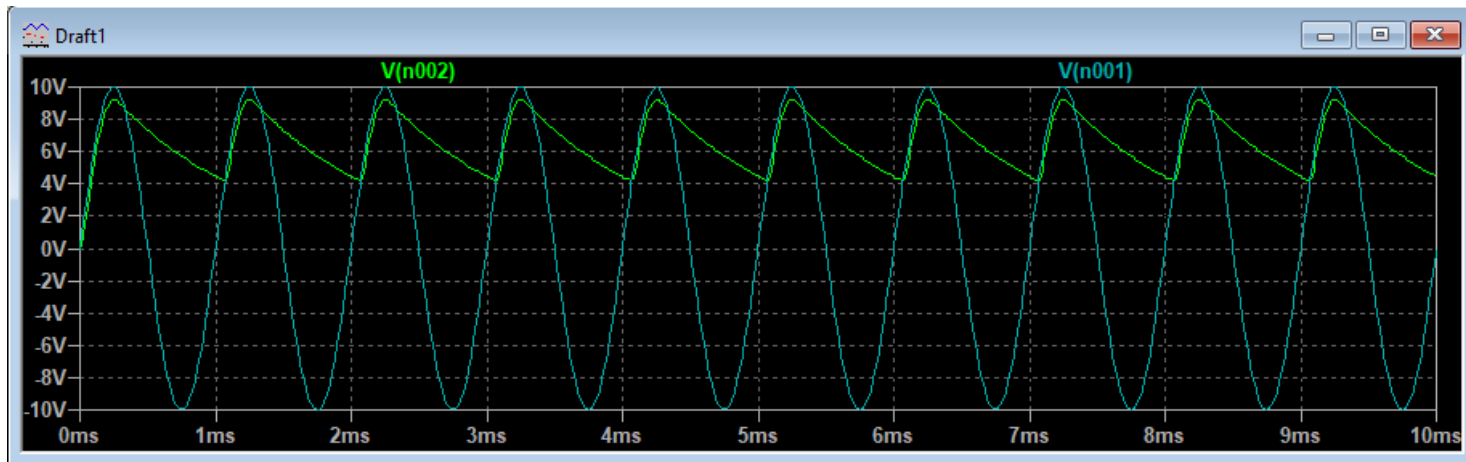
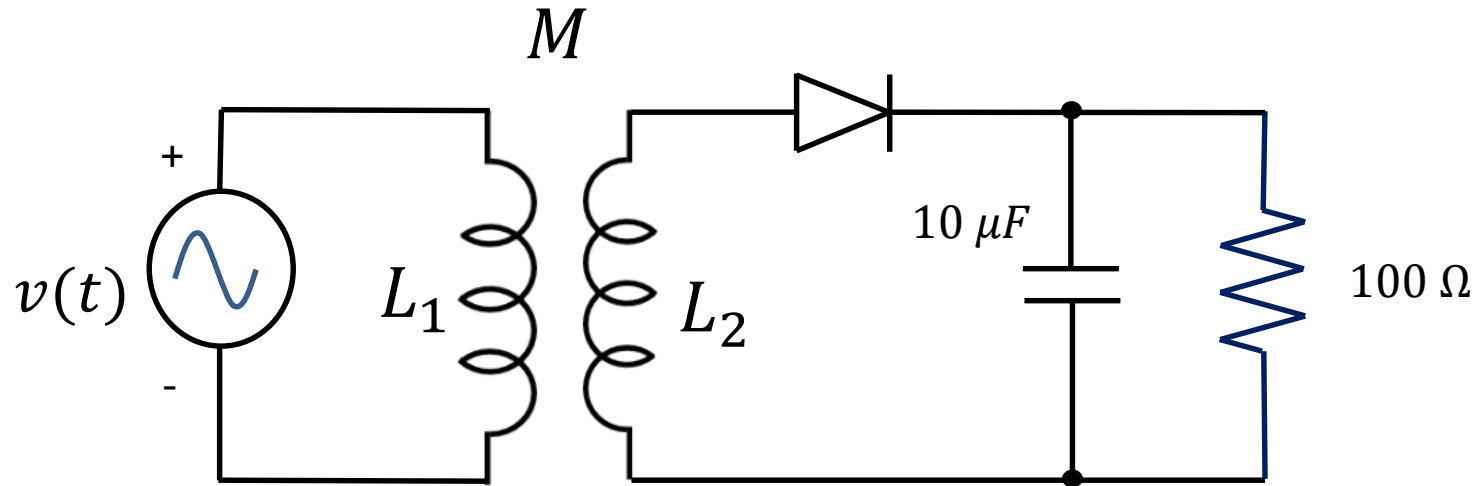


# Diode Circuits

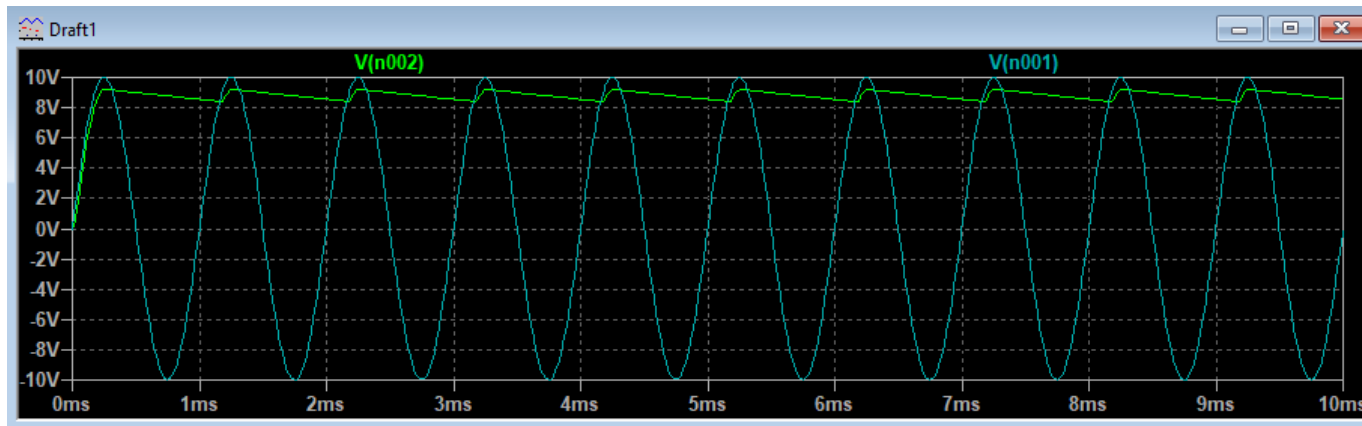
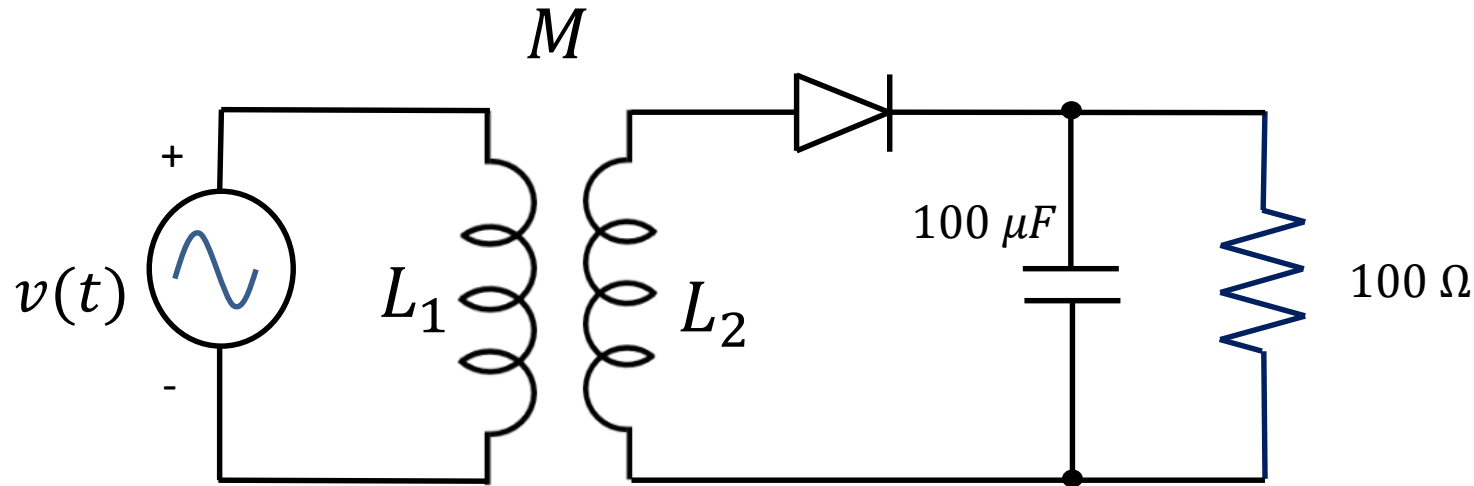
- Rectifiers:



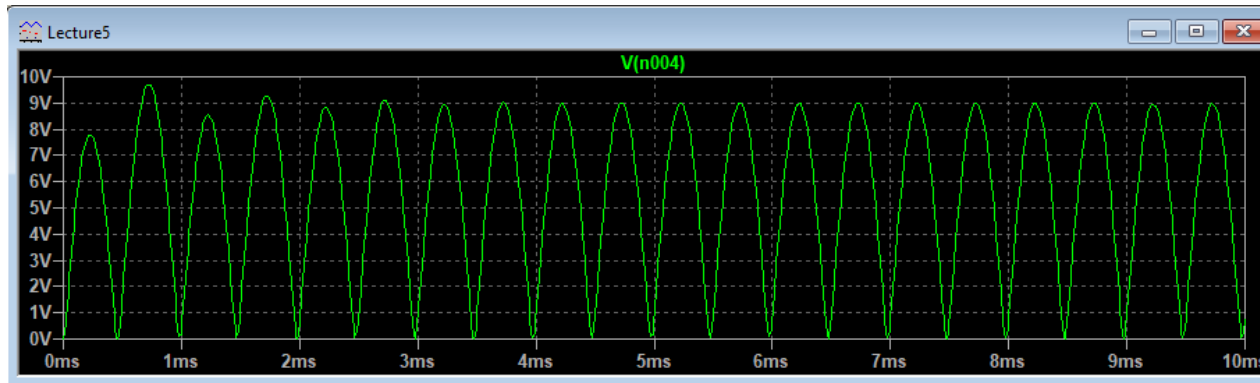
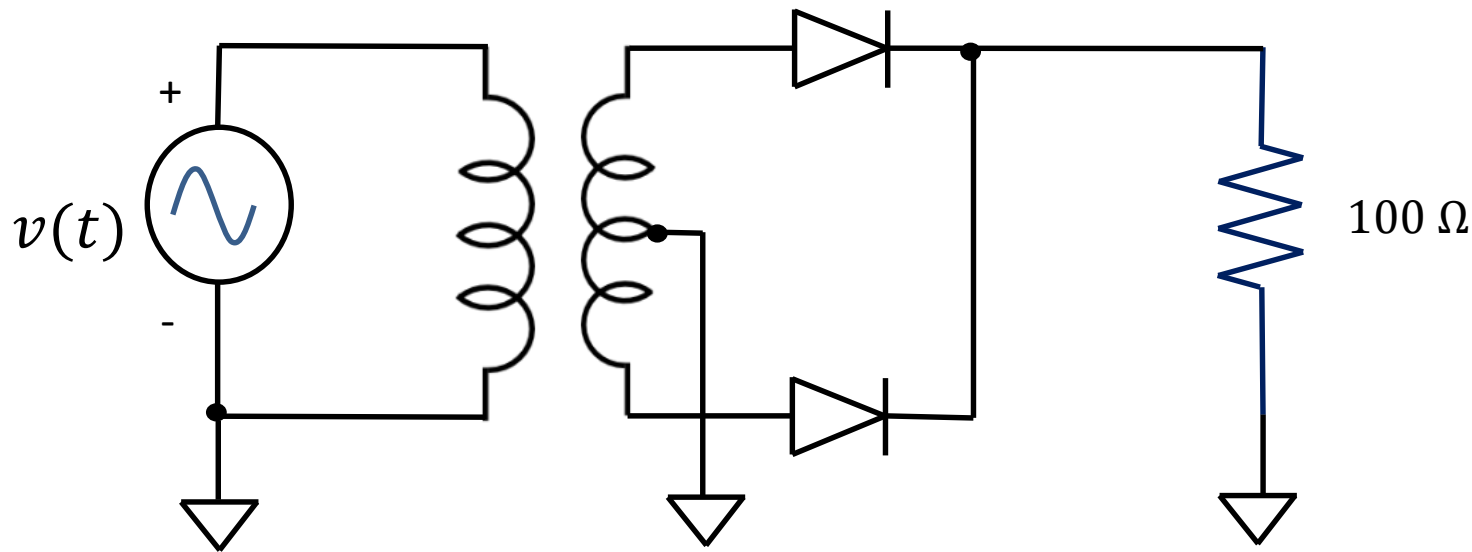
# Typical DC Power Supply Circuit



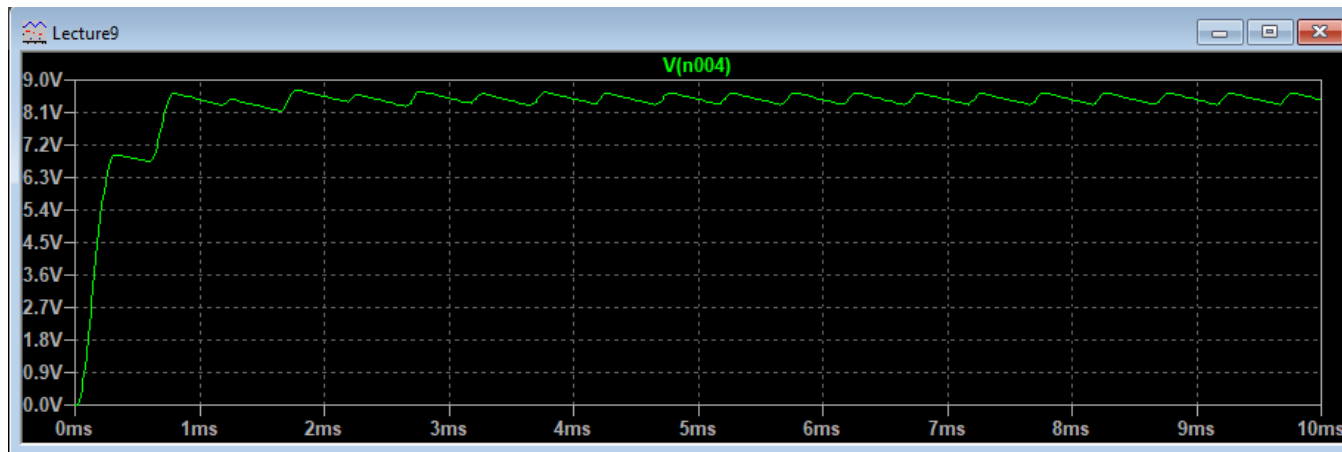
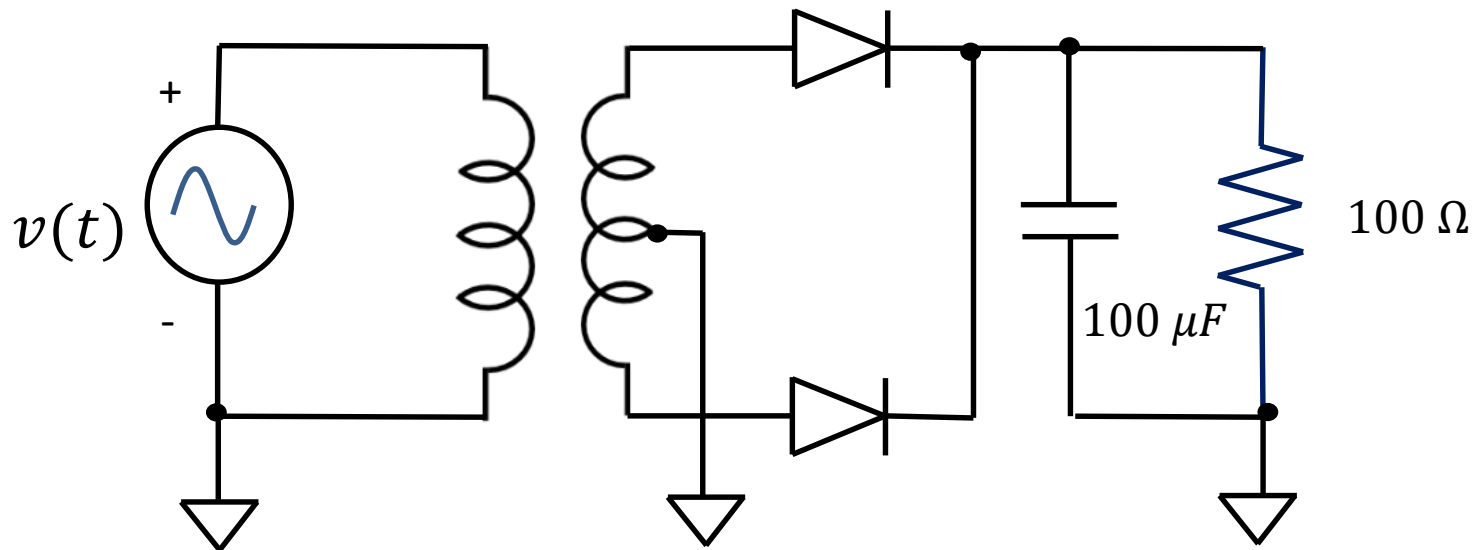
# Typical DC Power Supply Circuit



# Typical DC Power Supply Circuit



# Typical DC Power Supply Circuit



# Typical DC Power Supply Circuit

